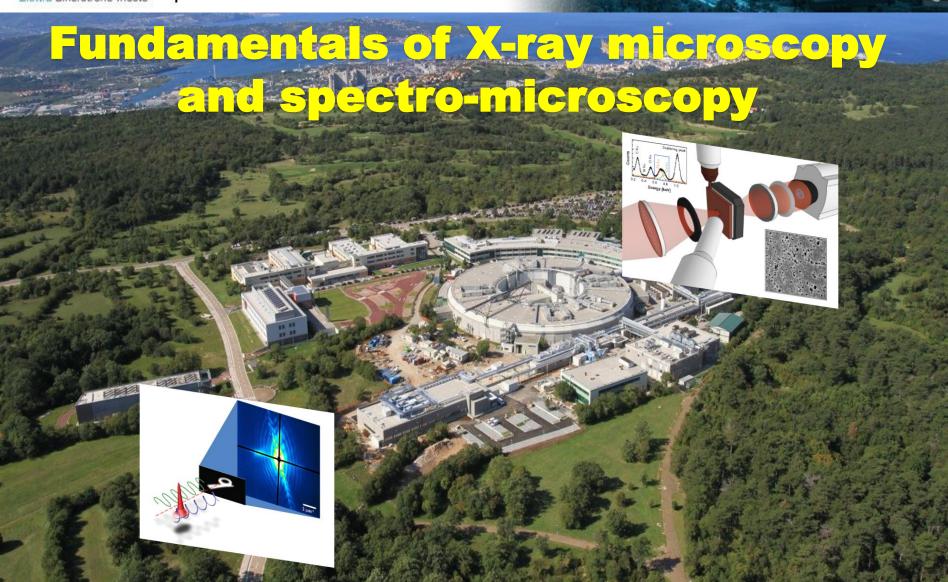


Elettra and FERMI lightsources



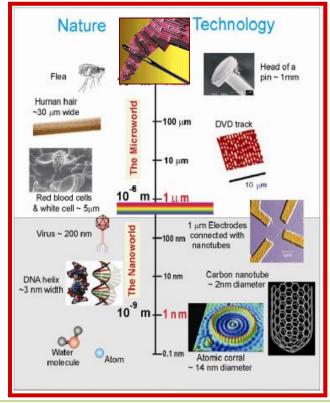






An Invitation to Enter a New Field of Physics & Material Science There's Plenty of Room at the BottomRichard P. Feynman - 1959!!!





'NANO'
by nature, design or externally-induced changes

- •Materials properties vary at various depth and length scales: atomic, nano or meso dimensions.
- •Structure and chemical composition unally is different at the surface and in the bulk.
- New properties expected with decreasing the dimensions stepping into nanoworld.

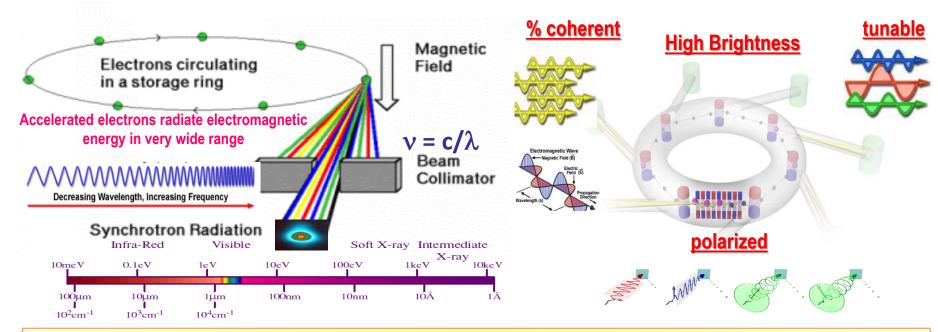
What we NEED:

Chemical sensitivity, spatial resolution & morphology & structure, varying probing depth, temporal resolution when possible.

Majority of these methods are based on interaction of the matter with photon, electron or ion radiation.



Why Microscopy needs Synchrotrons

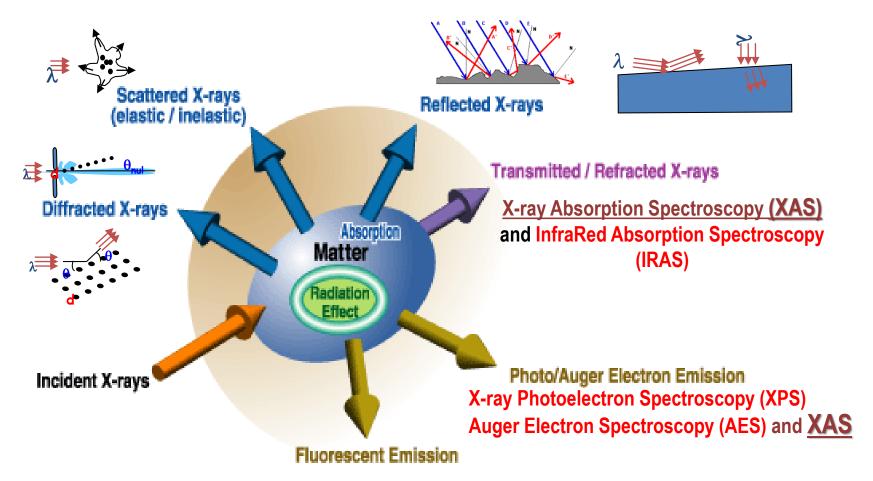


Synchrotron light advantages

- Very bright, wave-length tunable (cross sections and atomic edges), multiply polarized (dichroic effects, bonding orientation), partly coherent.
- Great variety of spectroscopies elemental, chemical, magnetic information.
- Variety of imaging contrasts based on photon absorption, scattering or spectroscopic feature.
- Higher penetration power compared to charged particles less sensible to sample environment.



All methods using SR are based on the interaction of photons with the matter and find applications in all domains of science and technology

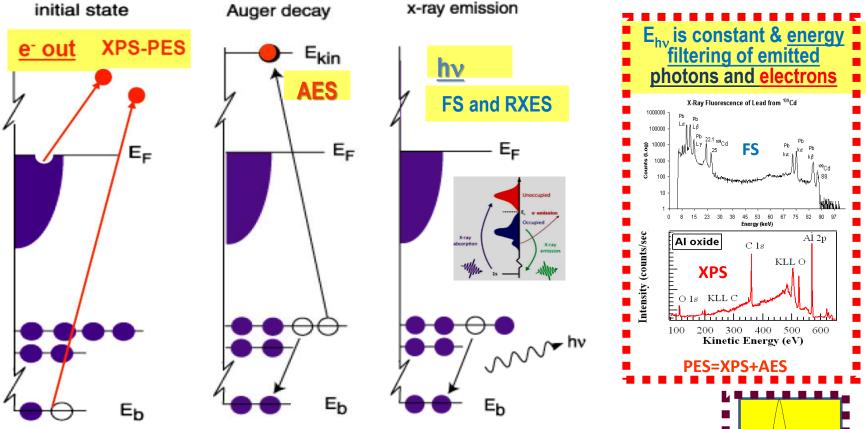


Fluorescence Spectroscopy (FS), RXES and XAS



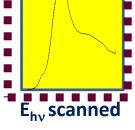
Spectroscopies @ synchrotron light sources: XPS-AES, XES, XAS

Photoelectric effect & de-excitation processes = chemical specific spectroscopies



XAS: based on absorption coefficient $\mu = f(\underline{h\nu}-E_{core})$ and resonant electronic transitions governed by selection rules.

e- and hy detection.



Maya Kiskinova

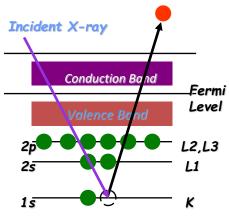


X-ray PhotoElectron Spectroscopy detects the electron emission, known as XPS, PES or ESCA (Electron Spectroscopy for Chemical Analysis).

Fermi

Level

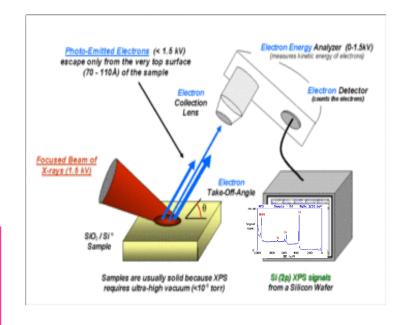
L2.L3



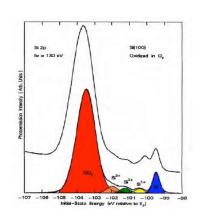
- 1s St. L. Auger electronserve energy
- XPS spectral lines are identified by the shell from which the electron was ejected (1s, 2s, 2p, etc.).
- The ejected photoelectron has kinetic energy: KE=hv-BE-f
- KLL Auger electron emitted to conserve energy released.

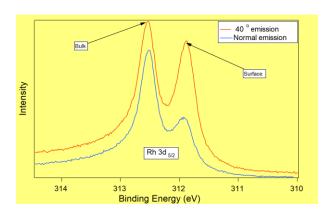
Conduction Band

■The KE of the emitted Auger electron is: KE=E(K)-E(L2)-E(L3).



'Chemical shifts' due to chemical bond in solid state or different coordination of emitting atom.

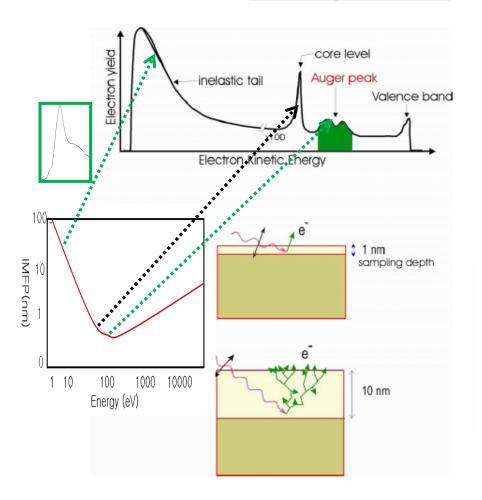




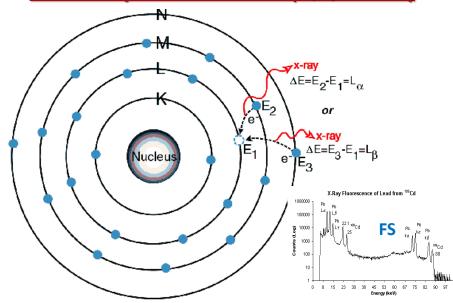


Sampling depths: depend on the detected signal (electrons or photons)

TEY& Auger electron emission (XAS), core&valence PES: Probe depth 1- 10 nm



Fluorescence emission (XAS and FS): Probe depth > 100 nm = f(E_{ph}, matrix)



X-ray transmission: 'bulk'

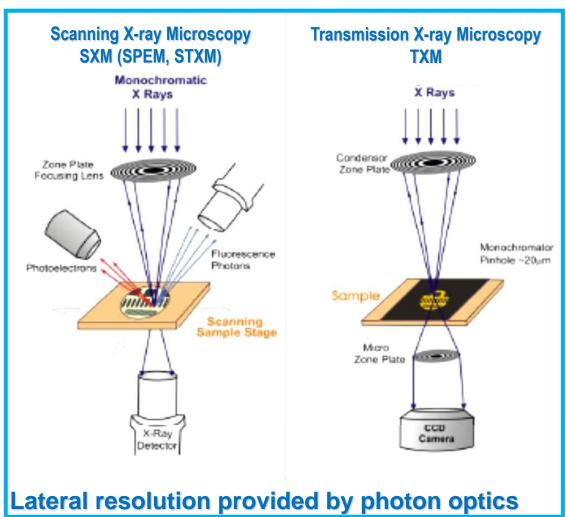
$$I_{o} = I_{o} e^{-\mu}$$

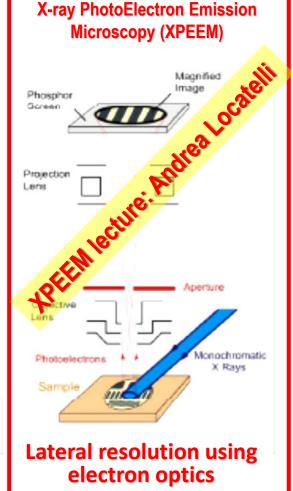


Microscopy Approaches:

X-ray or electron optics; X-ray or electron detection

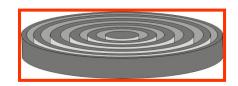
XRF, XPS, XAS = elemental and chemical information; X-ray transmission and scattering = morphology; Topology – electron emission





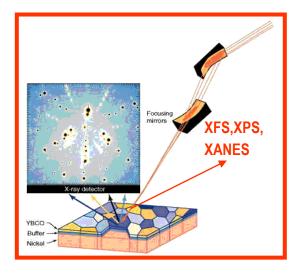


X-ray focusing optics: zone plates, mirrors, capillaries



Zone Plate optics: from ~ 200 to ~ 10000 eV

Monochromatic:
Resolution achieved 15 nm in transmission

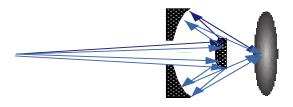


KP-B mirrors each focusing in one direction: soft & hard: ~

1000 nm

Soft & hard x-rays!

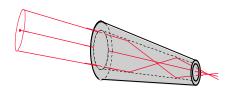
achromatic focal point, easy
energy tunability, comfortable
working distance
Resolution ≤ 100 nm



Normal incidence: spherical mirrors with multilayer interference coating (Schwarzschild Objective)

Monochromatic, good for <u>E < 100eV</u> Resolution: best ~ 100 nm

Capillary: multiple reflection concentrator



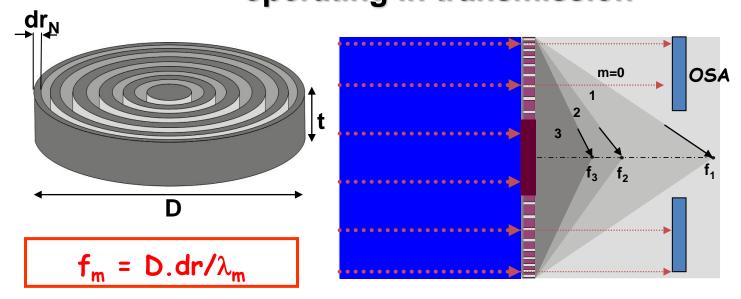
Hard x-rays ~ 8-18 keV Resolution: > 3000 nm

Refractive lenses



Hard x-rays ~ 4-70 keV Resolution: > 1000 nm

Zone plate: circular diffraction grating of N lines with radially decreasing line width operating in transmission



Important parameters:

Finest zone width, dr_N (10-100 nm) - determines

the Rayleigh resolution (microprobe size) δt =0.61 λ /(θ) =1.22 δr_N

Diameter, D (50-250 μm) determines the focal distance f.

Efficiency % of diffracted x-rays: 10-40% (4-25%)

Monochromaticity required: $\lambda/d\lambda \ge N$ (increases with dr and D).



X-ray transmission microscope (TXM-FFIM)

Full-field X-ray imaging or "direct" X-ray image acquisition can be considered as an optical analog to visible light transmission microscope.

Günther Schmahl, 1st experiment DESY 1976



X-ray light from a

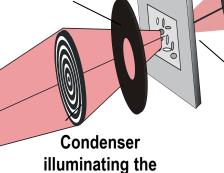
Synchrotron or

Lab light

source

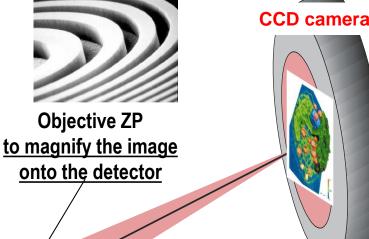
Aperture:

removes (i) unwanted diffraction orders and straylight, and serves (ii) with condenser as monochromator



object field

Specimen environment: to be adapted to application



Measuring
Graticule

Revolving
Nosepiece

Objective
Mechanical
Stage

Objective
Mechanical
Stage

Ocident
Mikon
Ecilipse E200
Student
Microscope

Field Lens
Field Lens
Control
Collector
Lens

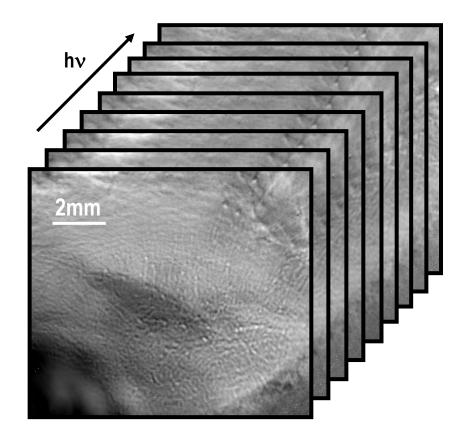
Resolution achieved better than 15 nm.

Maya Kiskinova



Spectro-microscopy (XANES) with TXM-FFIM:

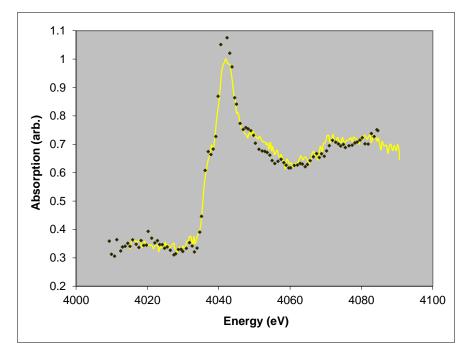
requires collection of a set of images at different photon energy



Trabecular bone of a mouse femur sample (10µm thick); Image field is 27 x 21 µm²

Study dealing with genetic determinism of immobilization induced bone loss with the FFIM at ID21, ESRF, France (Ca XANES)

M Salome et al

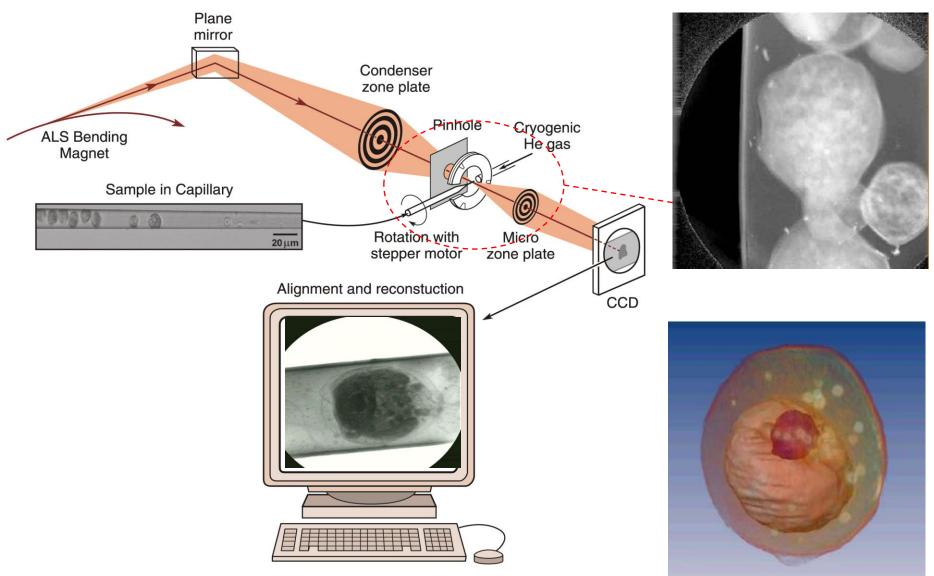


Hydroxy-apatite spectrum recovered from a stack of 200 images





Cryogenic 3D imaging of biological cells



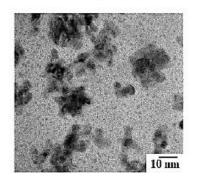


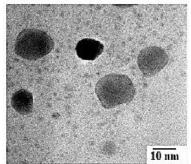
Following dynamic processes during temperature treatment, applying magnetic/electric field or pumping with optical lasers X

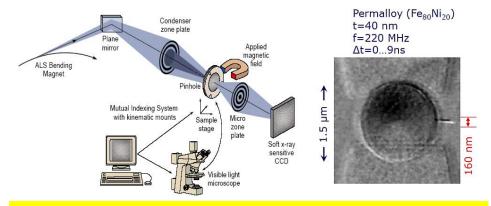
Fe38Rh62 nanoparticles

as-deposited

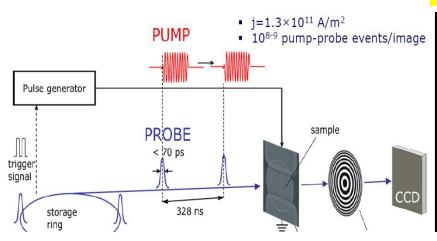
after annealing

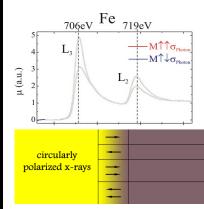


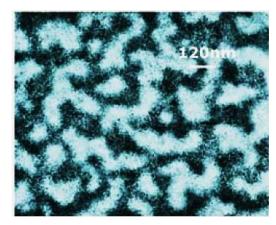




XAS-XMCD X-Ray Magnetic Circular Dichroism







X-ray Scanning Microscopy: uses focusing x-ray optics (preferred zone plates) Imaging in Transmission & Emission + Nano-micro spot spectroscopy

Janos Kirz, 1st operating STXM 1983 SPEM 1990, STXM+XRF 1995



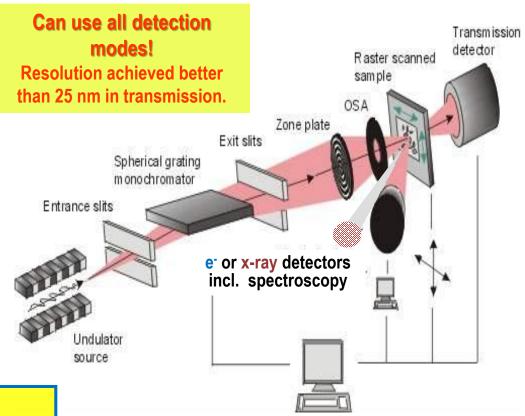


Image contrast

- Density, thickness, morphology (incl. phase contrast and ptychography);
 - > Element presence and concentration;
 - Chemical state, band-bending, charging;
 - Magnetic spin or bond orientation.

Microspectroscopy:

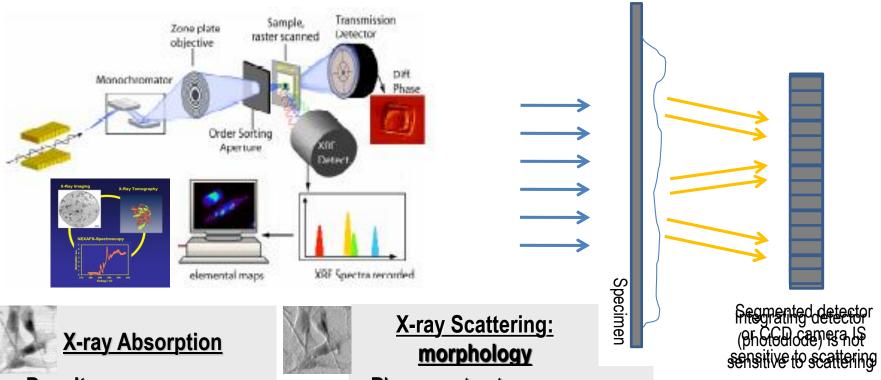
μ-XPS, μ-XANES or μ-XES (XRF) from selected spots — detailed chemical and electronic structure of coexisting micro-phases.





SXM: contrast based on photon detection Bulk sensitive

COMPLEMENTARY: transmission & XRF + XANES



Density

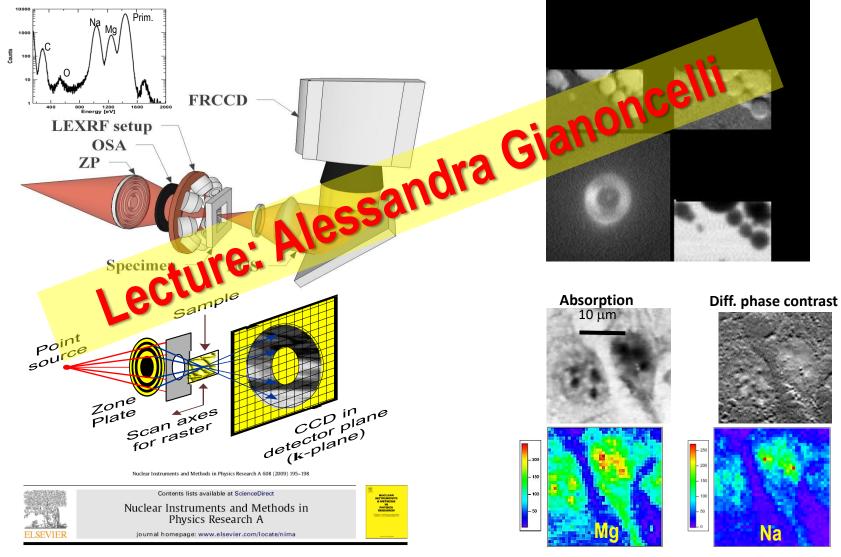
Chemical-magnetic contrast: XAS

- Phase contrast phase change encoded by refractive index, δ .
- Ptychography

The number of photons absorbed within thickness x is given as number N of photons penetrating to depth x, times the number n of absorbers per unit volume and the absorption cross section σ : $dN/dx = -Nn\sigma$ or $N = N_0 \exp(-n\sigma x)$.



Simultaneous acquisition of absorption and phase-sensitive X-ray transmitted signals & XRF



Simultaneous soft X-ray transmission and emission microscopy

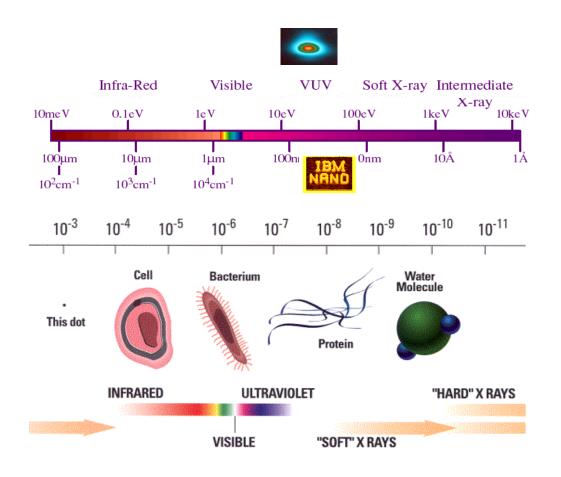
A. Gianoncelli ^{a,*}, B. Kaulich ^a, R. Alberti ^{b,c}, T. Klatka ^{b,c}, A. Longoni ^{b,c}, A. de Marco ^d, A. Marcello ^d, M. Kiskinova ^a

Epatocytes from human liver



Advantages of microscopy using in-out X-rays

Optical resolution scales with the light wavelength

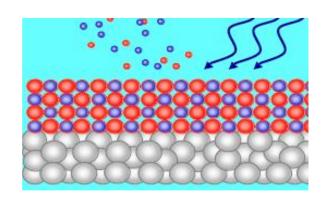


- Orders of magnitude higher penetration power of X-rays compared to charged particles.
- Elemental, chemical and magnetic sensitivity using multiple spectroscopies
- Multiple Imaging contrasts: transmission, emission, scattering.
- Imaging in solid or liquid environment is easier



Information from emitted electrons

- Qualitative and quantitative elemental information: Core Level spectra.
- Chemical composition and chemical bonding: Core Level shifts.
- Valence band: LOCAL electronic structure (micro-ARPES).
- Sensitivity to local structure (micro-XPD).
- XMCD-XMLD with secondary electrons (XAS).
- Information depth < 10 nm (surface sensitive).

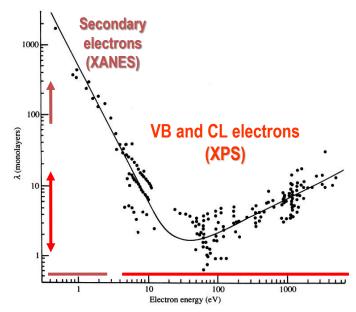


Information depth = d.sinq d = Electron Escape depth ~ 3-15 atomic layers for PES; XAS upto 100 atomic layers

q = Emission angle relative to surface

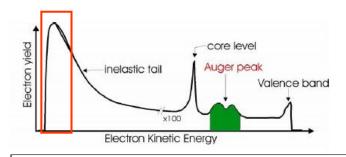
DOS F-VBC PHOTOEM, INTENSITY TO BE B DOS PHOTOEM, INTENSITY The bear of the bear of

Electron Mean Free Path

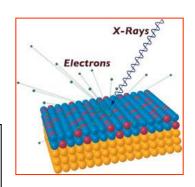


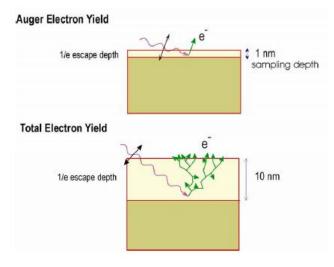


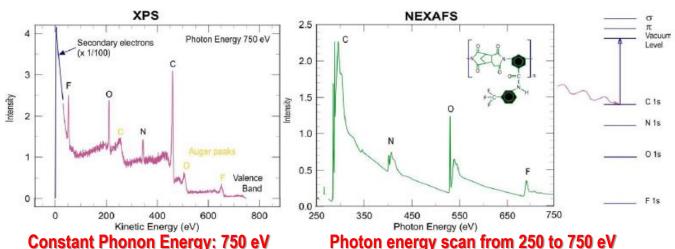
XAS and XPS using electron detection

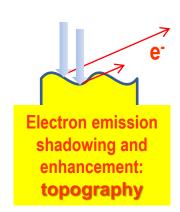


NEXAFS electron KE < 50 eV: the core electron emission is negligibly weak compared to the inellastic secondary electron signal





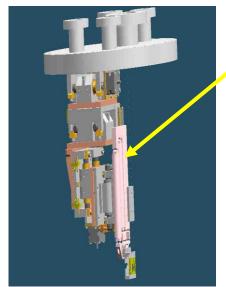


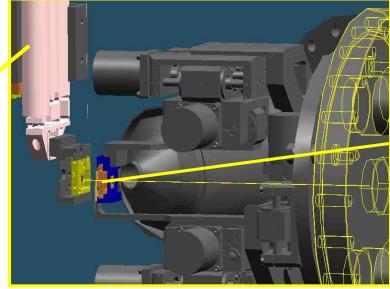


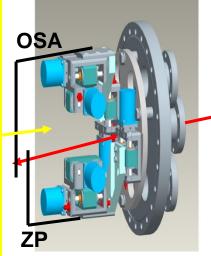
Photon energy scan from 250 to 750 eV

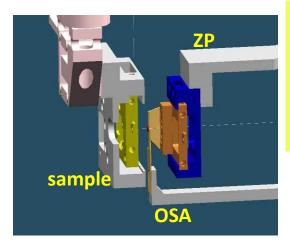


Layout of SPEM: ZP optics, sample and positioning systems





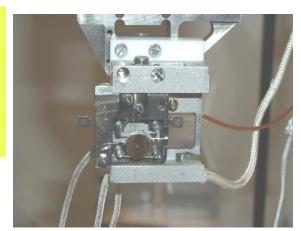




Spatial resolution in emission limited by the sample-to-optics distance ! $f_m = D_x dr_x E_{ph} / 1240$ Ranging around 10 mm

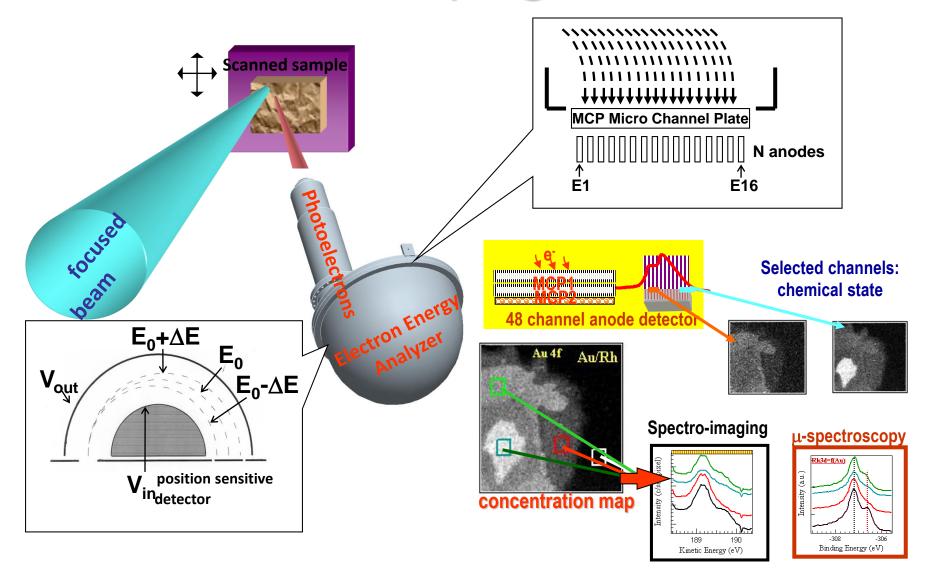
$$DOF = \frac{\delta r}{D} f_m$$

Typical: 5-15 μm





SPEMs energy-filtering electron analysers MCD developed @ ELETTRA



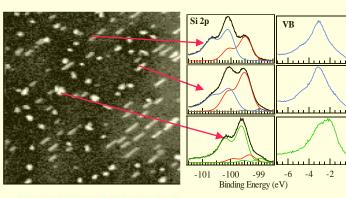


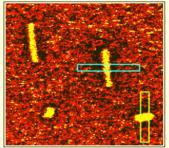
Local chemistry at the metal/ semiconductor interfaces and 'inhomogeneous' oxidation of metals

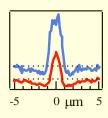


L. Gregoratti et al, PRB 57 (98) L2134, PRB 59 (99)

Ni/Si interface: mass transport and coexisting 19, NiSi and NiSi₂ phases



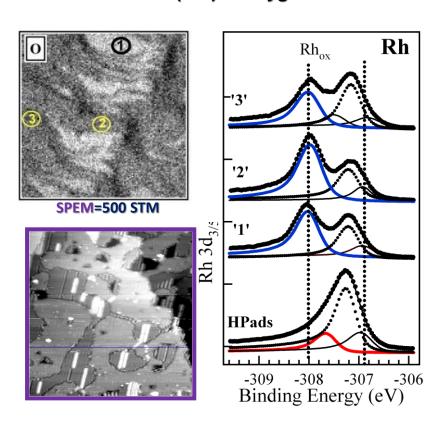




- Identified the presence of a NiSi phase.
- Determined the mobility of Ni in the different phases

P. Dudin et al, J. Chem Phys. 1019 (2005)

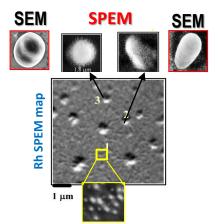
O 2p maps & Rh 3d μ-PES after exposure of Rh(110) to oxygen





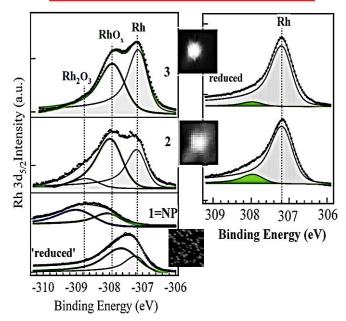
Model catalyst systems studied with SPEM:

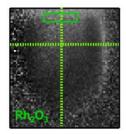
supported Rh metal particles on MgO

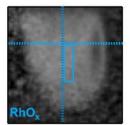


SPEM Rhox Rhmet 309.0 308.0 307.0

No simple size effect on reactivity in oxidative and reductive ambient



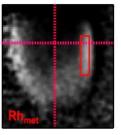




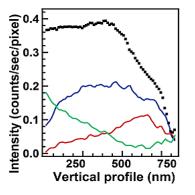
Rh 3d_{5/2}

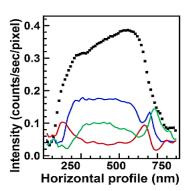
Lateral variation of Rh oxidation state

within $\sim 1 \mu m^2$ supported Rh particle



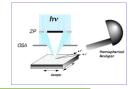
Binding Energy (eV)



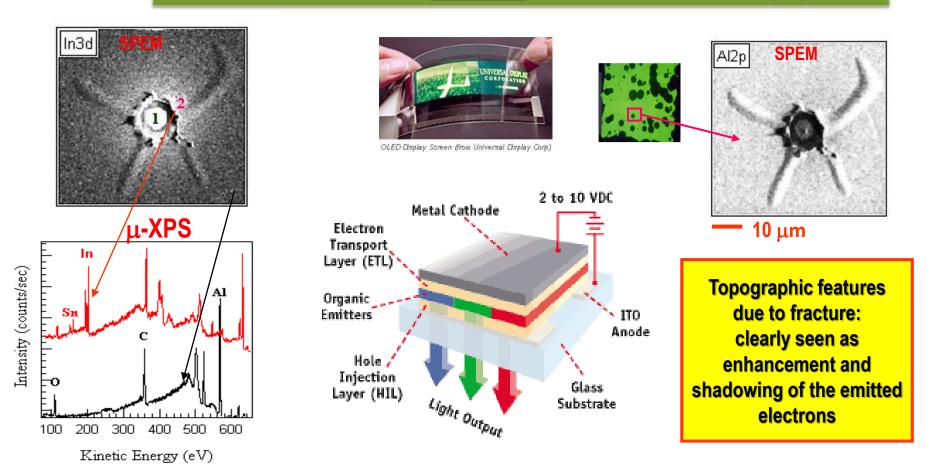




Degradation of organic light emission devices: mechanism revealed by 'in-situ' SPEM



OLED exposed to ambient: moisture? supposed to be the damaging factor

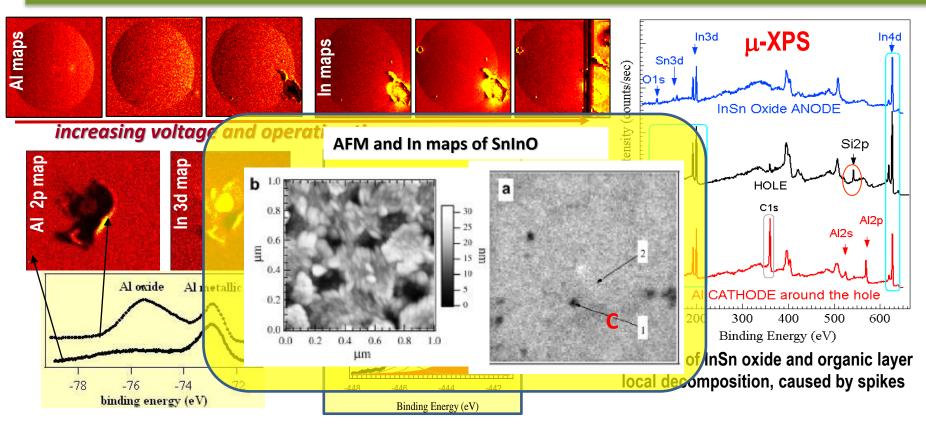


Chemical imaging & µ-XPS revealed anode material (In and Sn) deposited around the hole created in the Al cathode of OLEDs.



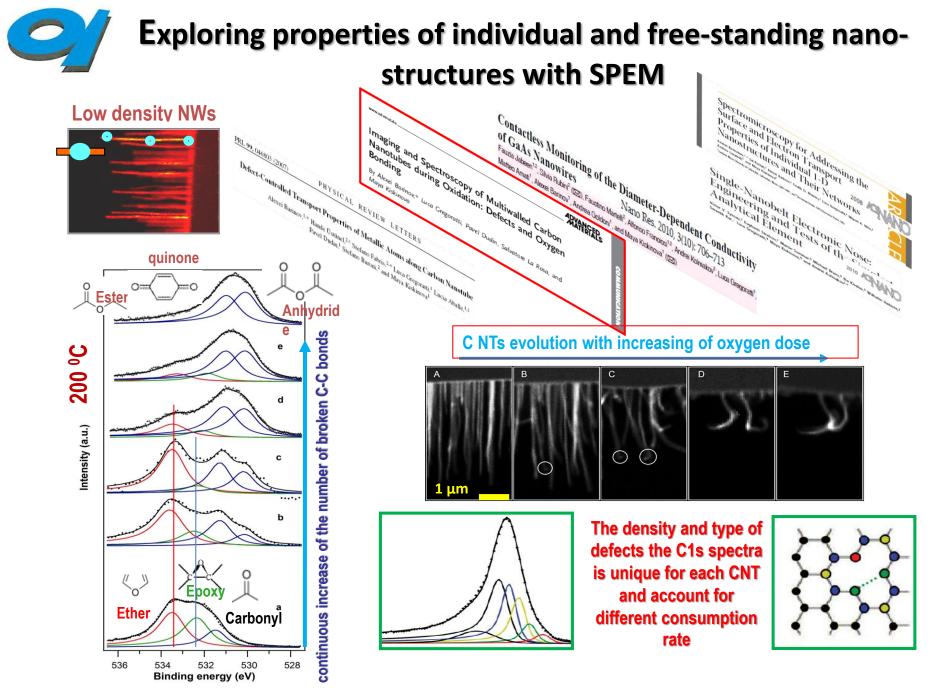
'In-situ' imaging of the local deformation and fracturing of the OLED cathode surface

"Clean" experiment: OLED growth and operated in the SPEM (UHV ambient): failure due to light emission in absence of humidity!



Lateral variations of the surface topography and chemistry of the InSn oxide anode films suggested as the major reasons for the device failures.

P. Melpigniano et al, APL 86, 41105, S. Gardonio, Org.Electr. 9, 253

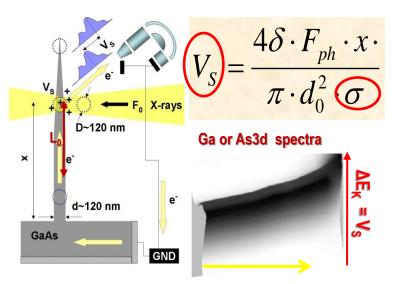


Surface potential V_s & GaAs NWs conductivity, σ :

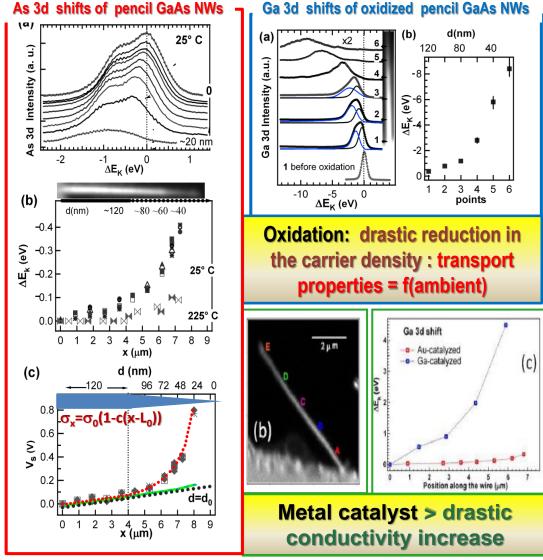
non-ohmic behavior with reducing diameter, environment effects, effect of growth conditions

$$E_K = E_{Ko} \pm E_{BB} \pm E_{SPV} - V_s$$

V_s = f(Ohmic neutr. current)



- Conductivity of pencil-like NWs: nonohmic behavior as a function of d.
- ❖ The data fit to linear decrease of ♂ with decreasing d. confirms size effects

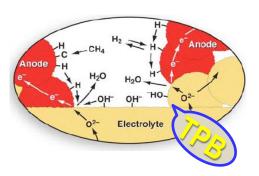


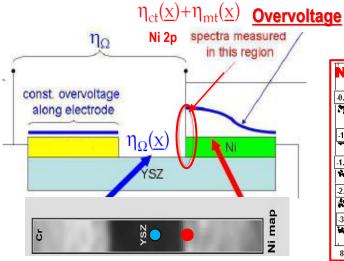


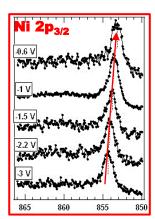
SOFCs under operating conditions with SPEM:

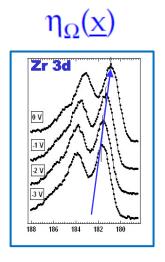
local chemical state and overpotential

O₂ reduction at the cathode, diffusion of the O- through a electrolyte, and oxidation of the fuel by at the anode.

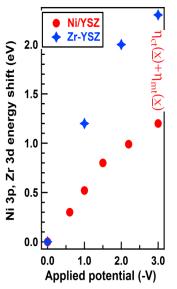






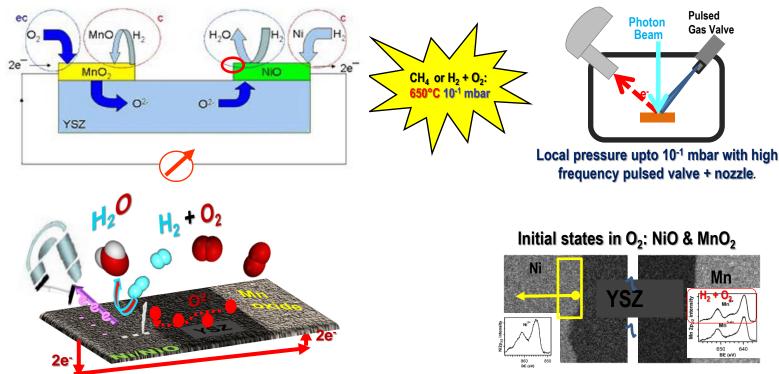


- Activation over-potentials represent chemical energy needed to overcome charge transfer barrier.
- The potential contributions: ohmic $\eta_{\Omega}(x)$, charge transfer, $\eta_{ch}(x)$, and mass-transport of electroactive species, $\eta_{mt}(x)$, :depend on the location within the cell.
- The highest contributions of charge-transfer and species transport are at the electrode-electrolyte interface where the electrochemical reactions occur.
- Overvoltage contribution can be measured from CL shifts,





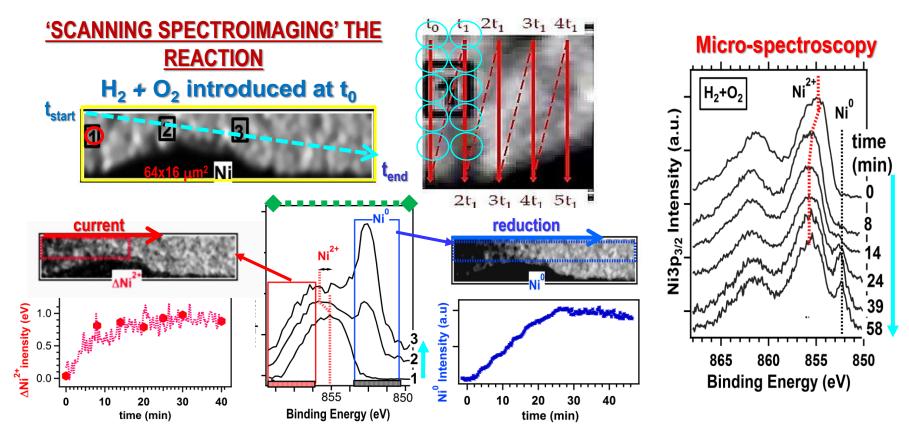
Self-driven single Mn oxide/Ni cell:



The spectral transients, recorded under operating conditions resulting in generation of electric current, encodes both: (1) time-dependent electrochemical kinetics (current flow) through rigid spectral energy shifts and the electrodes oxidation states resulting from the electrochemical and chemical processes through CL chem. shifts.



Single Mn/Ni cell: simultaneous monitoring reduction and current during reaction



Steady state overpotential ~ 0.8 eV ~ 10 min: in concert with thermodynamic predictions for the potential generated by the electrochemical reaction:

$$\Delta G(10^{-5} \text{ mbar})=-322 \text{ kJ/mol} \Rightarrow E=0.83 \text{ V}$$

Steady state chemical state ~ 30 min: anodic oxidation and chemical reduction concur.





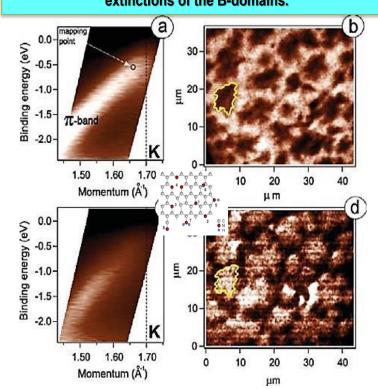
μ-ARPES SPEM @ Elettra

NANOLETTERS

D. Usachov et al

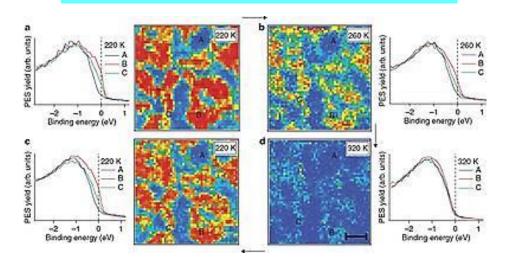
The real space structure of graphene domains, visualized with PE microscopy at different PE azimuthal angles, corresponding to the highest intensity of the π -band in the mapping point.

μ-ARPES of quasi-free standing N-doped graphene: EVIDENCE OF COEXISTENCE OF AT LEAST TWO DOMAINS ROTATED BY 30 deg: found T-dependence and extinctions of the B-domains.



Domain formation during Metal-Insulator Transitions

Spatial distribution of the photoelectron intensity for the d band reveal the evolution during the metal-insulator transition in Cr-doped V₂O₃ with decreasing T, microscopic domains become metallic and coexist with an insulating background.

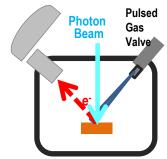


S. Lupi et al., Nature Comm. 1, 105 (2010)



Outlook and challenges

For μ-PES: In-situ measurements of nano-structures under realistic ambient conditions: options to overcome the UHV limitations.



Local pressure upto 10⁻¹ mbar with high frequency pulsed valve + nozzle M.Amati et al, J. Instr.8, 2013, T05001.

G-windows robust, impermeable and electron transparent

nature nanotechnology Vol. 6, 2011, 651 ARTICLES NUMBER OF AUTOMATICAL PROPERTY OF THE PROPERT

Nanoscale 2014, DOI: 10.1039/c4nr03561e

Photoelectron spectroscopy of wet and gaseous samples through graphene membranes†

Graphene oxide windows for *in situ* environmental scell photoelectron spectroscopy

Jürgen Kraus, ^a Robert Reichelt, ^a Sebastian Günther, ^a Luca Gregoratti, ^b Matteo Amati, ^b Maya Kiskinova, ^b Alexander Yulaev, ^{c.a} Ivan Vlassiouk ^d and Andrei Kolmakov ^e

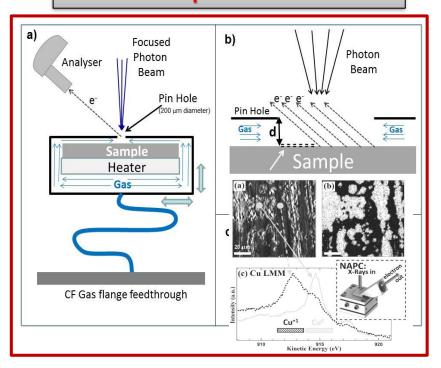


Top Catal (2016) 59:448-468

Recent Approaches for Bridging the Pressure Gap in Photoelectron Microspectroscopy

Andrei Kolmakov¹ · Luca Gregoratti² · Maya Kiskinova² · Sebastian Günther³

SPEM set-up with reaction cell





Classical X-ray imaging and spectromicroscopy: brief outline

SURFACES & INTERFACES: XPEEM and SPEM

BULK Information STXM/SPEM & TXM

PHOTON-IN/ ELECTRON-OUT (probing depth=f(E_{el}) max ~ 20 nm)

PHOTON-IN/PHOTON-OUT (probing depth = $f(E_{ph}) > 100 \text{ nm}$)

Spectroscopy (XPS-AES-XANES)
ONLY CONDUCTIVE SAMPLES

(Spectroscopy - XFS or XANES)

<u>Total e⁻ yield</u> (sample current)

XANES

Total hy yield, Transmitted x-rays

- Chemical surface sensitivity:
 Quantitative μ-XPS (0.01 ML)
- ➤ Chemical & electronic (VB) structure

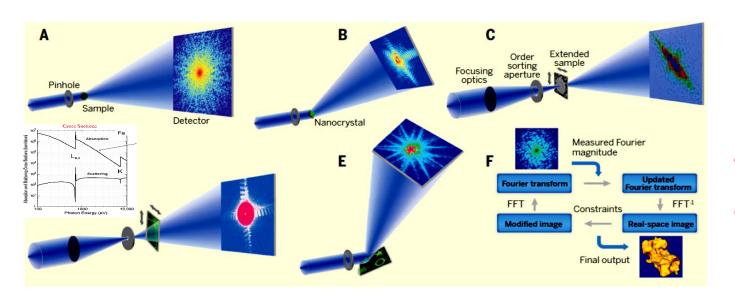
Chemical bulk sensitivity
Quantitative μ-XFS
Trace element mapping

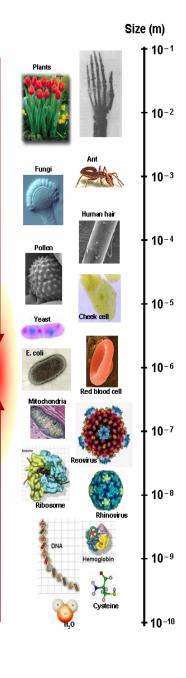


Imaging-resolution-time

- All 'classical x-ray microscopy'- <u>limited in resolution</u> focal depth by the optical elements. Time resolution ≥ 0.1 ns.
- ➤ Transmission electron microscopes can resolve even atoms but are <u>limited in penetration</u> (samples thinner than ~ 30 nm).

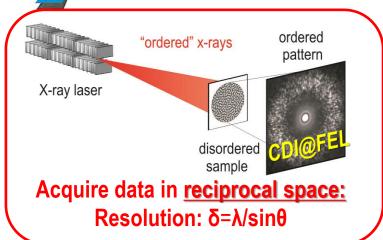
The optics depth and resolution limitations can be overcome by image reconstruction from measured <u>coherent</u> X ray scattering pattern visualizing the electron density of non-crystalline sample. Tuning to the atomic edges adds speciation.





maging

Single shot Coherent Diffraction Imaging (CDI)





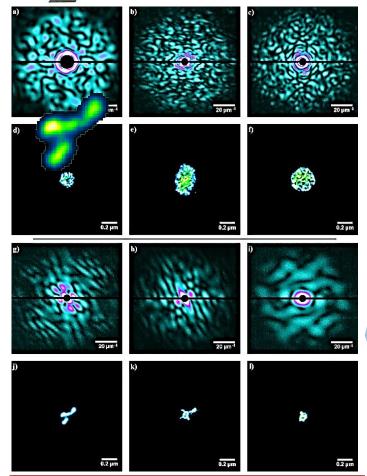




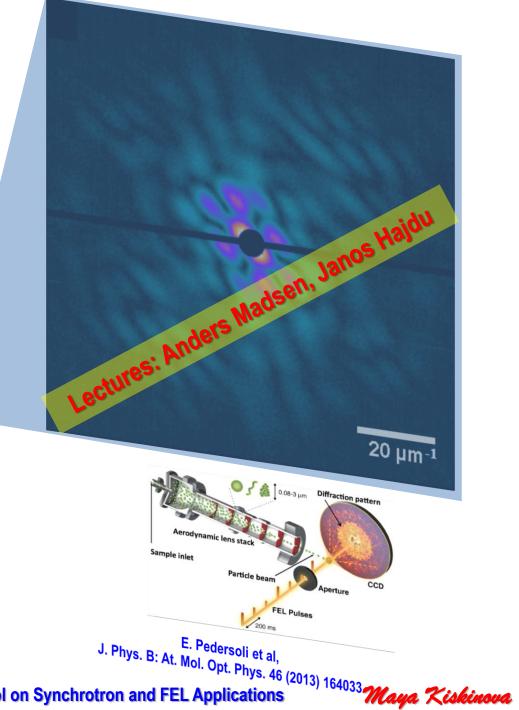
Structure and dynamic phenomena in morphologically complex, disordered or particulate matter – Fermi's spectral purity is an asset!

using phase retrieval





Appealing to explore the new collective properties resulting from the secondary structures of the assembled NP





Enjoy the following Lectures

X-ray microscopy: absorption, phase contrast, ptychography

(Lecture Alessandra Gianoncelli)

- 2D/3D morphology
 - High resolution.
- Density mapping.

Hard X-ray Imaging and tomography (Lecture Giuliana Tromba) X-ray (Coherent) Scattering

(Anders Madsen, Janos Hajdu)

- Structure: stress/strain/texture 2D/3D mapping.
 - Chemistry at resonances

SXM - XRF and XAS

(Lecture: Alessandra Gianoncelli)

- Elemental quantification
 - Elemental mapping
 - Bulk sensitive

Photoelectron imaging and Spectromicroscopy with XPEEM:

(Lecture: Andrea Locatelli)

- Chemical state
- Chemical and magnetic mapping.
 - Surface sensitive.

Infrared Spectromicroscopy (Lecture: Lisa Vaccari)

- Molecular groups and structure
 - High S/N for organic matter
 - Functional group imaging.
- Modest resolution but non-destructive radiation.

